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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/585,001	06/29/2006	Toshihiko Tsuji	128591	4937
25944 OLIFF & BERI	7590 08/06/200 RIDGE, PLC	EXAMINER		
P.O. BOX 3208	350	SMYTH, ANDREW P		
ALEXANDRIA	A, VA 22320-4850		ART UNIT	PAPER NUMBER
			2881	
			MAIL DATE	DELIVERY MODE
			08/06/2009	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

		Appli	cation No.	Applicant(s)				
Office Action Summary			35,001	TSUJI ET AL.				
		Exam		Art Unit	T			
	•		REW SMYTH	2881				
	The MAILING DATE of this communi				 ddress			
Period fo		oution appears of	Tine devel enect	min the correspondence a	uurooo			
WHIC - Exter after - If NC - Failu Any I	ORTENED STATUTORY PERIOD FOR CHEVER IS LONGER, FROM THE MASSIONS OF time may be available under the provisions SIX (6) MONTHS from the mailing date of this common period for reply is specified above, the maximum state to reply within the set or extended period for reply eply received by the Office later than three months a part of the provision	AILING DATE Of of 37 CFR 1.136(a). In a unication. atutory period will apply a will, by statute, cause th	F THIS COMMUN no event, however, may a and will expire SIX (6) MO e application to become a	IICATION. a reply be timely filed DNTHS from the mailing date of this ABANDONED (35 U.S.C. § 133).	•			
Status								
1) 又	Posnonsivo to communication(s) file	d on 05/04/2000						
2a)□	Responsive to communication(s) filed on <u>05/04/2009</u> . This action is FINAL . 2b)⊠ This action is non-final.							
3)□	/ 							
J)الــا	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
	closed in accordance with the practic	ce under Ex parte	, Quayle, 1900 O.	.D. 11, 400 O.O. 210.				
Dispositi	on of Claims							
4)🛛	Claim(s) 1-39 is/are pending in the a	pplication.						
	4a) Of the above claim(s) is/are withdrawn from consideration.							
5)🛛	✓ Claim(s) 7-15,17-25,29 and 30 is/are allowed.							
6)🖂								
· <u> </u>	Claim(s) 4,6,32 and 37 is/are objected	-						
8)	Claim(s) are subject to restric	tion and/or election	on requirement.					
Applicati	on Papers							
Application Papers 9)☐ The specification is objected to by the Examiner.								
•	The drawing(s) filed on is/are:		or b)□ objected to	n by the Examiner				
.0/	Applicant may not request that any object							
		_	• •		`ED 1 101/d\			
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).								
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.								
Priority ι	ınder 35 U.S.C. § 119							
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 								
2) 🔲 Notic 3) 🔯 Inform	t(s) e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (P nation Disclosure Statement(s) (PTO/SB/08) r No(s)/Mail Date <u>06/29/2006, 07/31/2007</u> .	TO-948)	Paper No	v Summary (PTO-413) o(s)/Mail Date f Informal Patent Application 				

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DETAILED ACTION

Response to Request for Continued Examination (RCE)

- 1. Claims 1-25 have been amended.
- 2. Claims 26-39 are new claims.
- 3. Claims 7-15 and 17-25 were previously allowed in Final Rejection of 11/04/2008.

Previously allowed claims 7-15 and 17-25 were amended to replace the word "said" with the word "the". The subject matter of the claims remains unchanged.

Response to Arguments

1. Applicant's arguments with respect to claim1-6 and 16 have been considered but are most in view of the new ground(s) of rejection.

Claim Objections

1. Claims 4, 6, 32, and 37 objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Concerning claims 4, 6, 32, and 37; the search failed to find the vibration isolation device for supporting the optical member and preventing vibrations from traveling through the device along the optical axis and also a control device for moving the vibration isolation device in the optical axis direction if a detector is triggered.

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Allowable Subject Matter

1. Claims 29-30 are allowed.

2. Dependent claims 29-30 are allowable due to dependency upon previously allowed independent claim 7.

Claim Rejections - 35 USC § 112

1. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

2. Claims 5, 33, 35 recites the limitation "a second vibration isolation device" or "the vibration isolation device" in claim 1. There is insufficient antecedent basis for this limitation in the claim.

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.
- 2. Claims 1-3, 16, 26-28, 31, 34, 36, and 38-39 are rejected under 35 U.S.C. 102(e) as being anticipated by Kayama et al. (US 2007/0081133).

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Regarding claim 1, Kayama et al. teaches an exposure apparatus that has an optical member/ projection unit (figure 1, PU) for transferring a pattern from a mask (figure 1, R) onto a substrate (W); a movable member/XY stage (31) below the optical member/ projection unit, which supports the substrate and moves perpendicularly to the optical axis of the optical member/ projection unit; a detector (18, 17), on a periphery of the optical member/ projection unit, for detecting the position of the movable member/XY stage or of the substrate along the optical axis direction; and a device/controller (19, 20) for receiving position information from the detector and controlling the movement of the movable member/XY stage in a direction perpendicular to the optical axis of the optical member/ projection unit [0057; 0077, 0159].

Regarding claim 2, Kayama et al. teaches an elevating device/wafer stage drive (24) for moving the movable member/XY stage in the optical axis direction [0159], wherein the control device (20, 19) controls the elevating device/wafer stage drive based on measurements of the detector to move the movable member/XY stage away from the optical member/ projection unit along the optical axis direction [0050; 0149; 0159].

Regarding claim 3, Kayama et al. teaches that the detector is positioned in multiple positions (18, 17, 15, 16), at greater distances from the optical member/ projection unit

(PU), in directions perpendicular to the optical axis (AX), than the stopping distance of the movable member/XY stage .

Regarding claim 26, Kayama et al. teaches that the exposure apparatus has a multiple detectors (18, 17, 16, 15), and, in response to detection results assigned to the multiple detectors, the controller instructs the movable member/XY stage to execute different movements [0057; 0077, 0159].

Regarding claim 27, Kayama et al. teaches that in response to the detected position of the movable member/XY stage (31) or of the substrate along the optical axis, the controller (20, 19, 24) instructs the movable member/XY stage to execute different movements [0057; 0077, 0159].

Regarding claim 28, Kayama et al. teaches that a measurement by the detector (17, 18, 20) reflects the movement status of the movable member/XY stage [0057; 0077, 0159].

Regarding claim 31, Kayama et al. teaches an exposure apparatus, in which the space between an optical member/ projection unit (figure 1; PU) which projects a pattern (R) onto object/wafer (W) placed on the image-plane side of the optical member/ projection unit is filled with a liquid [0027], and the pattern exposure is transferred through the liquid [0027]; wherein an opposing member/reticle stage (RST)

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, positioned apart from the object/wafer in the direction the optical axis of the optical member/ projection unit (AX, PU), a driving device/reticle stage drive (11) [0043, 0045] to drive the opposing member/reticle stage and a controller(20), when triggered, moves the object/wafer and the opposing member/reticle stage apart along the optical axis, wherein the opposing member/reticle stage is movable, relative to the optical member/ projection unit, in the optical axis direction [0043, 0045; 0149; 0159].

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Regarding claim 34, Kayama et al. teaches that the object/wafer is movable [0043, 0045; 0149; 0159] perpendicular to the optical axis (24), and the controller (20), when triggered, moves the object/wafer and the opposing member/reticle stage apart along the optical axis direction [0159].

Regarding claim 36, Kayama et al. teaches that the object/wafer is a substrate (W) for exposure to a pattern (R) or a movable member/XY stage (31) for supporting the substrate, and movable with at least three degrees of freedom [0159].

Regarding claim 38, Kayama et al. teaches that the controller, when triggered by an earthquake, moves the object/wafer and the opposing member/reticle stage apart along the optical axis direction [0159].

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Regarding claims 16 and 39, Kayama et al. teaches a device manufacturing method, comprising a lithography process which uses an exposure apparatus (title, abstract).

Conclusion

1. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Pertinent prior art is closely related art that individually or in combination could be considered grounds for rejection. See references cited for a listing of the pertinent prior art found and the prior art found.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Andrew Smyth whose telephone number is 571-270-1746. The examiner can normally be reached on 7:30AM - 5:00PM; Monday thru Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robert Kim can be reached on 571-272-2293. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/A. S./

Examiner, Art Unit 2881

/David A Vanore/

Primary Examiner, Art Unit 2881